

Figure 1

Thicknesses (nm) achieved by placing several coatings of film through a number of dip coat and annealing cycles with a constant withdrawal rate (120 cm min<sup>-1</sup>) in the synthesis of TiO<sub>2</sub> and nAuAg-TiO<sub>2</sub> on glass (System 2).

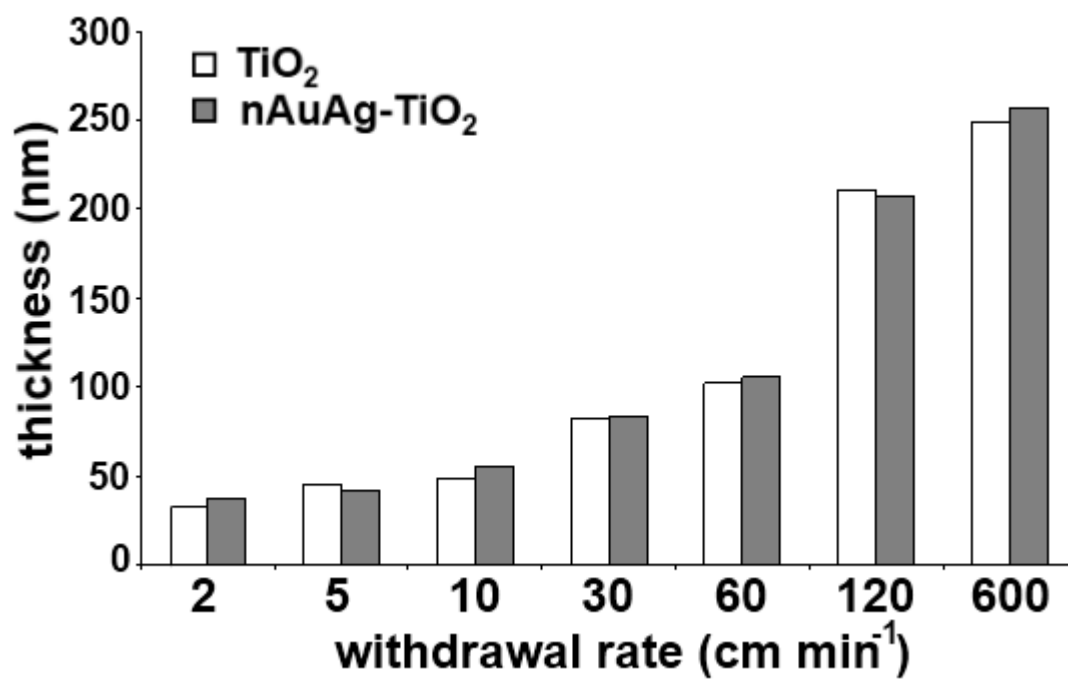


Figure 2  
Thicknesses (nm) achieved by varying the withdrawal rate from the sol in the synthesis of TiO<sub>2</sub> and nAuAg-TiO<sub>2</sub> on glass (System 1).